



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re patent application of: KEZUKA ET AL.

Serial No.: 09/856,361

Filed: May 22, 2001

For: ETCHING SOLUTION, ETCHED ARTICLE AND
METHOD FOR ETCHED ARTICLE

Examiner: Goudreau

Art Unit: 1763

Docket No.: P07222US00/BAS

Patent

#8
AB
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RESPONSE TO RESTRICTION REQUIREMENT

Honorable Commissioner of Patents

Washington, D.C. 20231

SIR:

In response to the Restriction Requirement dated January 27, 2003, and without addressing the merits of the arguments therein, Applicants elect Group I, Claims 1-13, drawn to an etching composition.

Examination and allowance of these claims is thus respectfully requested.

Respectfully submitted,

March 26, 2003

B. Aaron Schulman
Registration No.: 31,877

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